



INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(51) International Patent Classification 6: H01L 29/772, 29/812, 29/205, 21/335, 21/20

(11) International Publication Number:

WO 99/66562

(43) International Publication Date: 23 December 1999 (23.12.99)

(21) International Application Number:

PCT/GB99/01940

A1

(22) International Filing Date:

18 June 1999 (18.06.99)

(30) Priority Data:

9813142.8

19 June 1998 (19.06.98)

GB

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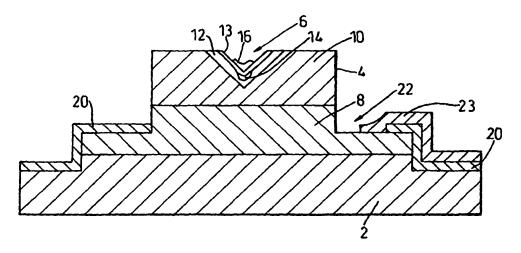
(81) Designated States: CN, GB, JP, KR, US, European patent (AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE).

Published

With international search report.

Before the expiration of the time limit for amending the claims and to be republished in the event of the receipt of amendments.

(54) Title: QUANTUM WIRE FIELD-EFFECT TRANSISTOR AND METHOD OF MAKING THE SAME



(57) Abstract

A quantum wire field-effect transistor having at least one, one-dimensional, elongate conducting means (14) provided by at least a first semiconductor layer surrounded by a wider bandgap, second semiconductor layer (12, 13) and extending between source (24) and drain (26) electrodes, and in which there is provided a backgate structure (8, 23) to control conduction in the elongate conducting means. The transistor can be a Single Electron Transistor (SET) wherein two adjacent gate electrodes (16, 18) are disposed over the elongate conducting means to induce a quantum dot (17) therein, and it can be made with the first semiconductor layer material as GaAs and the second semiconductor layer material as A1GaAs. A method of making the transistor involves preferentially growing the elongate conducting means at the bottom of a groove (6) lined with the second semiconductor layer (12).



From the INTERNATIONAL BUREAU

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NOTIFICATION OF ELECTION

(PCT Rule 61.2)

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Assistant Commissioner for Patents United States Patent and Trademark Office Box PCT Washington, D.C.20231 ÉTATS-UNIS D'AMÉRIQUE

10 February 2000 (10.02.00)	in its capacity as elected Office Applicant's or agent's file reference JL2156 Priority date (day/month/year) 19 June 1998 (19.06.98)		
International application No. PCT/GB99/01940			
International filing date (day/month/year) 18 June 1999 (18.06.99)			
Applicant			
JEFFERSON John Henry et al			

	International Preliminary Examining Authority	on:
	10 January 2000 (10.01.00)	
in a notice effecting later ele	oction filed with the International Bureau on:	
The election X was		
was not		
made before the expiration of 19 n Rule 32.2(b).	nonths from the priority date or, where Rule 32	applies, within the time limit under

The International Bureau of WIPO 34, chemin des Colombettes 1211 Geneva 20, Switzerland Authorized officer

Olivia RANAIVOJAONA

Facsimile No.: (41-22) 740.14.35

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'ATENT COOPERATION THE ATY

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NOTIFICATION THAT INTERNATIONAL **APPLICATION CONSIDERED TO BE** WITHDRAWN

(PCT Article 14(1), (3) or (4) and Rule 29.1)

From the INTERNATIONAL BUREAU

To:

Assistant Commissioner for Patents United States Patent and Trademark Office **Box PCT** Washington, D.C.20231 ÉTATS-UNIS D'AMÉRIQUE

	in its capacity as designated Office		
Date of mailing (day/month/year) 24 September 1999 (24.09.99)	IMPORTANT NOTIFICATION		
24 September 1999 (24.09.99)			
International application No.	International filing date (day/month/year)		
PCT/GB99/01980	23 June 1999 (23.06.99)		
Applicant			
MARS U.K. LIMITED et al			
applicant that the international application is to be consider	ember 1999 (07.09.99)		
The International Bureau of WIPO	Authorized officer		
34, chemin des Colombettes 1211 Geneva 20, Switzerland	F. Gateau		
Facsimile No.: (41-22) 740.14.35	Telephone No.: (41-22) 338.83.38		

Form PCT/IB/325 (February 1994)

002862630

INTERNATIONAL SEARCH REPORT

(PCT Article 18 and Rules 43 and 44)

Applicant's or agent's file reference		f Transmittal of International Search Report 20) as well as, where applicable, item 5 below.			
JL2156	ACTION (FORTH PCT/ISA/2)	20) as well as, where applicable, lieff 5 below.			
International application No.	International filing date (day/month/year)	(Earliest) Priority Date (day/month/year)			
PCT/GB 99/01940	18/06/1999	19/06/1998			
Applicant					
THE SECRETARY OF STATE FO	R DEFENCE of al				
THE SECRETARY OF STATE FOR	The contract of all				
This International Search Report has been according to Article 18. A copy is being tra	n prepared by this International Searching Auth ansmitted to the International Bureau.	nority and is transmitted to the applicant			
This International Search Report consists [X] It is also accompanied by	of a total of sheets. a copy of each prior art document cited in this	report.			
Basis of the report					
	international search was carried out on the bas ess otherwise indicated under this item.	sis of the international application in the			
the international search w Authority (Rule 23.1(b)).	as carried out on the basis of a translation of the	ne international application furnished to this			
b. With regard to any nucleotide an was carried out on the basis of the		ternational application, the international search			
contained in the internation	nal application in written form.				
	rnational application in computer readable form	1.			
1 =	this Authority in written form.				
١ ' ' '	this Authority in computer readble form.	and the disalgeurs in the			
	sequently furnished written sequence listing do s filed has been furnished.	oes not go peyona the discrosure in the			
the statement that the info furnished	the statement that the information recorded in computer readable form is identical to the written sequence listing has been furnished				
2. Certain claims were fou	nd unsearchable (See Box I).				
3. Unity of invention is lact	king (see Box II).				
4. With regard to the title,					
the text is approved as su	bmitted by the applicant.				
	hed by this Authority to read as follows:				
QUANTUM WIRE FIELD-EFF	FECT TRANSISTOR AND METHOD (OF MAKING THE SAME			
5. With regard to the abstract,					
the text is approved as su	bmitted by the applicant.				
the text has been established, according to Rule 38.2(b), by this Authority as it appears in Box III. The applicant may, within one month from the date of mailing of this international search report, submit comments to this Authority.					
6. The figure of the drawings to be publ	ished with the abstract is Figure No.	2			
X as suggested by the appli	cant.	None of the figures.			
because the applicant fail	ed to suggest a figure.				
because this figure better	characterizes the invention.				

Form PCT/ISA/210 (first sheet) (July 1998)

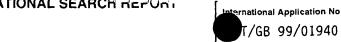
International application No.

PCT/GB 99/01940

Box III TEXT OF THE ABSTRACT (Continuation of item 5 of the first sheet)

The Abstract should be amended as follows; A quantum wire field-effect transistor having at least one, one-dimensional, elongate conducting means (14) provided by at least a first semiconductor layer surrounded by a wider bandgap, second semiconductor layer (12,13) and extending between source (24) and drain (26) electrodes, and in which there is provided a backgate structure (8,23) to control conduction in the elongate conducting means. The transistor can be a Single Electron Transistor (SET) wherein two adjacent gate electrodes (16,18) are disposed over the elongate conducting means to induce a quantum dot (17) therein, and it can be made with the first semiconductor layer material as GaAs and the second semiconductor layer material as AlGaAs. A method of making the transistor involves preferentially growing the elongate conducting means at the bottom of a groove (6) lined with the second semiconductor layer (12).

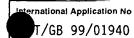
INTERNATIONAL SEARCH MERUMI



A. CLASSIFICATION OF SUBJECT MATTER
IPC 6 H01L29/772 H01L29/812 H01L21/335 H01L29/205 H01L21/20 According to International Patent Classification (IPC) or to both national classification and IPC B. FIELDS SEARCHED Minimum documentation searched (classification system followed by classification symbols) IPC 6 H01L Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched Electronic data base consulted during the international search (name of data base and, where practical, search terms used) C. DOCUMENTS CONSIDERED TO BE RELEVANT Relevant to claim No. Citation of document, with indication, where appropriate, of the relevant passages Category 6 EP 0 386 388 A (IBM CORP) 1-4,6,7,X 9,10,15, 12 September 1990 (1990-09-12) 16, 21-23, 25-27, 32,33, 38,39 Υ column 5, line 3 -column 8, line 50; 5,8, 11-14, figures 1-3 17-20, 24, 28-31. 34 - 37-/--Patent family members are listed in annex. Further documents are listed in the continuation of box C. χ Special categories of cited documents: "T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the "A" document defining the general state of the art which is not considered to be of particular relevance invention "E" earlier document but published on or after the international "X" document of particular relevance; the claimed invention filing date cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone "L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the citation or other special reason (as specified) "O" document referring to an oral disclosure, use, exhibition or document is combined with one or more other such docu other means ments, such combination being obvious to a person skilled document published prior to the international filing date but "&" document member of the same patent family later than the priority date claimed Date of the actual completion of the international search Date of mailing of the international search report 13/10/1999 1 October 1999 Name and mailing address of the ISA Authorized officer European Patent Office, P.B. 5818 Patentlaan 2 NL – 2280 HV Rijswijk Tel. (+31-70) 340-2040, Tx. 31 651 epo nl, Morvan, D Fax: (+31-70) 340-3016

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INTERNATIONAL SEARCH REPORT



		T/GB 99/01940
	ation) DOCUMENTS CONSIDERED TO BE RELEVANT	Delevents desired
Category °	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
Υ	WANG X-L ET AL: "FLOW RATE MODULATION EPITAXY OF ALGAAS/GAAS QUANTUM WIRES ON NONPLANAR SUBSTRATE" APPLIED PHYSICS LETTERS, vol. 66, no. 12, 20 March 1995 (1995-03-20), pages 1506-1508, XP000500907 ISSN: 0003-6951 page 1507, right-hand column, line 30 -page 1508, left-hand column, line 13; figure 4A	5,17-19, 28-31
Υ	WO 89 07832 A (BELL COMMUNICATIONS RES ET	8,34-36
Α	AL) 24 August 1989 (1989-08-24) page 5, line 2 -page 6, line 17; figures 1-4	11,20,37
Y	GB 2 295 272 A (TOSHIBA CAMBRIDGE RES CENTER) 22 May 1996 (1996-05-22) page 2, line 25 -page 4, line 15 page 6, line 4 -page 8, line 9; figures 1-3	11-14, 20,24,37

INTERNATIONAL SEARCH REPORT

ation on patent family members

	Inte	rnational	Application No
(T/GB	99/01940

Patent document cited in search report		Publication date	Patent family member(s)		Publication date	
EP 0386388	A	12-09-1990	CA JP US	2006266 A,C 2266514 A 5037776 A	10-09-1990 31-10-1990 06-08-1991	
WO 8907832	Α	24-08-1989	CA US US	1315865 A 4974036 A 5040032 A	06-04-1993 27-11-1990 13-08-1991	
GB 2295272	Α	22-05-1996	JP US	9051106 A 5701017 A	18-02-1997 23-12-1997	

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INTERNATIONAL PRELIMINARY EXAMINATION REPORT

(PCT Article 36 and Rule 70)

Applicant's or agent's file reference JL2156			FOR FURTHER ACTIO		ation of Transmittal of International Examination Report (Form PCT/IPEA/416)
International application No.			International filing date (day/n	nonth/year)	Priority date (day/month/year)
PCT/GB	99/01	940	18/06/1999		19/06/1998
International H01L29/		nt Classification (IPC) or nat	tional classification and IPC		
Applicant					
THE SEC	CRET	ARY OF STATE FOR	DEFENCE et al.		
		ational preliminary exami smitted to the applicant a		pared by this Inte	rnational Preliminary Examining Authority
2. This f	REPO	RT consists of a total of	7 sheets, including this cov	er sheet.	
b	This report is also accompanied by ANNEXES, i.e. sheets of the description, claims and/or drawings which have been amended and are the basis for this report and/or sheets containing rectifications made before this Authority (see Rule 70.16 and Section 607 of the Administrative Instructions under the PCT).				
These	ann	exes consist of a total of	5 sheets.		
3. This r	3. This report contains indications relating to the following items:				
I ⊠ Basis of the report					
11		Priority			
m		Non-establishment of o	pinion with regard to novelty	, inventive step	and industrial applicability
IV		Lack of unity of inventio	n		
٧	Ø		nder Article 35(2) with regard ons suporting such statemer		ntive step or industrial applicability;
VI		Certain documents cite			
VII	\boxtimes	Certain defects in the in	ternational application		
VIII	\boxtimes	Certain observations or	the international application		
Date of submission of the demand			Dat	e of completion of	this report
10/01/20	00		14.	09.2000	
		address of the international ning authority:	Aut	horized officer	Supple SORS MIEVER
European Patent Office D-80298 Munich Tel. +49 89 2399 - 0 Tx: 523656 ep			epmu d	orvan, D	
	Fax:	+49 89 2399 - 4465	Tele	ephone No. +49 89	2399 2258

INTERNATIONAL PRELIMINARY EXAMINATION REPORT

International application No. PCT/GB99/01940

. Bas	is of t	he re	port
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1. This report has been drawn on the basis of (substitute sheets which have been furnished to the receiving Office in response to an invitation under Article 14 are referred to in this report as "originally filed" and are not annexed to the report since they do not contain amendments.):

	the	report since they o	do not contain amendments.):	
	Des	scription, pages:		
	1-1	5	as originally filed	
	Cla	ims, No.:		
	1-3	2	with telefax of	12/07/2000
	Dra	wings, sheets:		
	1-4		as originally filed	
2.	The	amendments hav	re resulted in the cancellation of	f:
		the description,	pages:	
		the claims,	Nos.:	
		the drawings,	sheets:	
3.	Ø		een established as if (some of) beyond the disclosure as filed	the amendments had not been made, since they have been (Rule 70.2(c)):
		see separate sh	eet	
4.	Add	litional observatior	ns, if necessary:	

V. Reasoned statement und r Articl 35(2) with regard to novelty, inv ntiv step r industrial applicability; citations and explanations supporting such statement

1. Statement

Novelty (N)

Yes:

Claims 2, 3, 5, 7, 9-12, 15-18, 21-23, 27-32

No:

Claims 1, 4, 6, 8, 13, 14, 19, 20, 24, 25, 26

Inventive step (IS)

Yes: Claims

No:

Yes:

Claims 1-32

Industrial applicability (IA)

Claims 1-32

No: Claims

2. Citations and explanations

see separate sheet

VII. Certain defects in the international application

The following defects in the form or contents of the international application have been noted:

see separate sheet

VIII. Certain observations on the international application

The following observations on the clarity of the claims, description, and drawings or on the question whether the claims are fully supported by the description, are made:

see separate sheet

EXAMINATION REPORT - SEPARATE SHEET

Regarding Section I:

The set of claims does not meet the requirements of Article 34(2)(b) PCT since the amendments dated 12/07/00 introduce subject-matter which extends beyond the content of the application as filed:

- The feature of claim 1 stating that at least one wall of the groove is a substantially planar surface, roughly parallel to a crystal plane on which the growth rate of the first semiconductor is substantially zero cannot be derived as such from the original application documents, see in this respect figures 2 and 4 and original page 8, lines 13-25 and original page 12, line 16 original page 13, line 3, also the additional feature of dependent claim 2, which is properly supported by the original disclosure.
 A similar objection applies to the corresponding method feature of independent claim 19.
- 2. There is no basis either in the original application documents for the feature of claim 31 disclosing that quantum dots are provided in the vicinity of stops due to the thickness variations of the conducting means due to the off axis groove (it is noted that this would hold true if "steps" was used in lieu of "stops"), see in this respect page 9, lines 15-24.

Therefore, the amendments at issue have been disregarded under Rule 70.2(c) PCT.

Regarding Section V:

1. Reference is made to the following documents:

D1 = EP-A-0 386 388

D2 = Applied Physics Letters, vol. 66, no. 12, 20 March 1995, pages 1506-1508 (Wang et al.) D3 = WO 89/07832

D4 = GB-A-2 295 272

- 2. Insofar as the present text can be understood (see item VIII in this respect), the subject-matter of claims 1, 4, 6, 8, 13, 14, 19, 20, 24, 25 and 26 is not new in the sense of Rule 64(1)-(3) PCT, contrary to the requirements of Article 33(2) PCT:
- 2.1 D1 (see column 5, line 3 column 8, line 50 and figures 1-3) discloses a transistor having at least one, substantially one-dimensional, elongate conducting means provided by at least a first semiconductor (InGaAs (14; 24; 34, 36, 38)) substantially surrounded by a second semiconductor (InP (13, 15; 23, 25; 33, 35, 37, 39)) and extending between source and drain electrodes (26, 28), and in which there is provided at least one further electrode (27) in a region of the elongate conducting means. Furthermore, in the transistor of D1, the elongate conducting means are provided in a groove within the second semiconductor (adjacent the groove in the substrate).

Hence, all the features of claim 1 are known from D1 and the subject-matter of claim 1 is not new.

2.2 Furthermore, D1 (see the aforementioned passages, in particular figures 1(A)- 1(G) and the corresponding text) also discloses a method of providing a transistor comprising providing a substantially one-dimensional elongate conducting means by providing a first semiconductor (InGaAs (14; 24; 34, 36, 38)) substantially surrounded by a second semiconductor material (InP (13, 15; 23, 25; 33, 35, 37, 39)), providing a source electrode (26) at a first end region of the conducting means and a drain electrode (28) at a second end region of the conducting means, and providing at least one further gate electrode (27) in a region of the conducting means. Furthermore, the elongate conducting means are provided by creating a groove of second

semiconductor and subsequently providing the first semiconductor in the groove.

Hence, all the features of independent claim 19 are also known from D1. Therefore, the subject-matter of independent claim 19 is not new either.

- 2.3 The additional features of dependent claims 4, 6, 8, 13, 14, 20, 24, 25 and 26 are moreover obviously also known from D1.
 Therefore, the subject-matter of dependent claims 4, 6, 8, 13, 14, 20, 24, 25 and 26 is not new either.
- 3. Furthermore, insofar as the present text can be understood (see item VIII in this respect), the subject-matter of claims 2, 3, 5, 7, 9-12, 15-18, 21-23 and 27-32 does not involve an inventive step in the sense of Rule 65(1)-(2) PCT, contrary to the requirements of Article 33(3) PCT:
- 3.1 The additional features of dependent claims 2 and 3 would be regarded by the skilled person as relating to a mere technical equivalent to the configuration dealt with in D1, which can be interchanged with said configuration where circumstances make it desirable, see in this respect D1, column 6, lines 29-35 and D2, page 1507, right-hand column, line 30 page 1508, left-hand column, line 13 and figure 4(a). Hence, the subject-matter of dependent claims 2 and 3 lacks the required inventive step.
- 3.2 The additional features of dependent claims 5, 7, 9-12, 15-18, 21-23 and 27-32 are merely normal design options in the present technical field (see in particular eg. D2, page 1507, right-hand column, line 30 page 1508, left-hand column, line 13 and figure 4(a) regarding claims 5, 15-17, 22 and 27-29; D3, page 5, line 2 page 6, line 17 and figures 1-4 regarding claims 9, 18 and 30-32; D4, page 2, line 25 page 4, line 15, also page 6, line 4 page 8, line 9 and figures 1- 3 regarding claims 9, 10, 12, 18, 21 and 32). The skilled person would therefore readily consider including said features in the transistor and method known from D1.

Hence, the subject-matter of dependent claims 5, 7, 9-12, 15-18, 21-23 and 27-32 does not involve an inventive step.

4. The subject-matter of claims 1-32 is obviously susceptible of industrial application.

Regarding Section VII:

The following deficiencies have been noticed:

- 1. Contrary to the requirements of Rule 5.1(a)(ii) PCT, the relevant background art disclosed in the documents D1 to D4 is not mentioned in the description, nor are these documents identified therein.
- 2. The features of the claims are not provided with reference signs placed in parentheses, contrary to the requirements of Rule 6.2(b) PCT.

Regarding Section VIII:

The present application does not meet the requirements of Article 6 PCT because claims 1, 2, 5, 12, 13, 19, 22, 29 and 31 are not clear:

- 1. The term "substantially" used in claims 1, 2, 5, 13, 19, 22, 29 and 31 is vague and unclear and leaves the reader in doubt as to the meaning of the technical features to which it refers, thereby rendering the definition of the subject-matter of said claims unclear.
 - A similar objection applies to the unclear expression "hard confinement" used in claim 12 and to the term "stops" used in claim 31.